



Investigation of growth mechanism for highly oriented TiO₂ nanorods: the role of reaction time and annealing temperature

Bharat R. Bade^{1,4} · Sachin Rondiya² · Somnath R. Bhopale¹ · Nelson Y. Dzade² · Mahesh M. Kamble³ · Avinash Rokade⁴ · Mamta P. Nasane¹ · Mahendra A. More¹ · Sandesh R. Jadkar¹ · Adinath M. Funde⁴

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Abstract

Titanium dioxide (TiO₂) is a versatile and inexpensive material for extended applicability in several scientific and technological fields including photo-catalysis for industrial waste treatment, energy harvesting, and hydrogen production. In this work, we report the synthesis of TiO₂ thin film using hydrothermal method and investigations on the influence of reaction time and annealing temperature on growth mechanism of the TiO₂ nanorods. The synthesized TiO₂ films were studied by using UV–visible spectroscopy, Raman spectroscopy, X-ray diffraction (XRD), scanning electron microscope and energy-dispersive X-ray spectroscopy (EDS). The XRD and Raman measurements revealed the formation of defect free and pure tetragonal TiO₂ rutile phase. The TiO₂ thin films show absorption band edge at around 420 nm in the UV–visible spectrum and exhibit direct band gap value of 2.9 eV. The TiO₂ nanorods are demonstrated to grow randomly on the FTO substrate with changing reaction times but grow uniformly in a flower-like pattern with increasing annealing temperature. Investigation of the field emission properties of TiO₂ thin films (tested as field-emitter array) estimates the turn-on and threshold field at 4.06 and 7.06 V/μm at 10 and 100 μA/cm², respectively.

✉ Adinath M. Funde, adinathf@gmail.com | ¹Department of Physics, Savitribai Phule Pune University, Pune 411007, India. ²The School of Chemistry, Cardiff University, Cardiff CF10 3AT, Wales, UK. ³PDEA's Anantrao Pawar College, Pirangut, Mulshi, Pune 412115, India. ⁴The School of Energy Studies, Savitribai Phule Pune University, Pune 411007, India.



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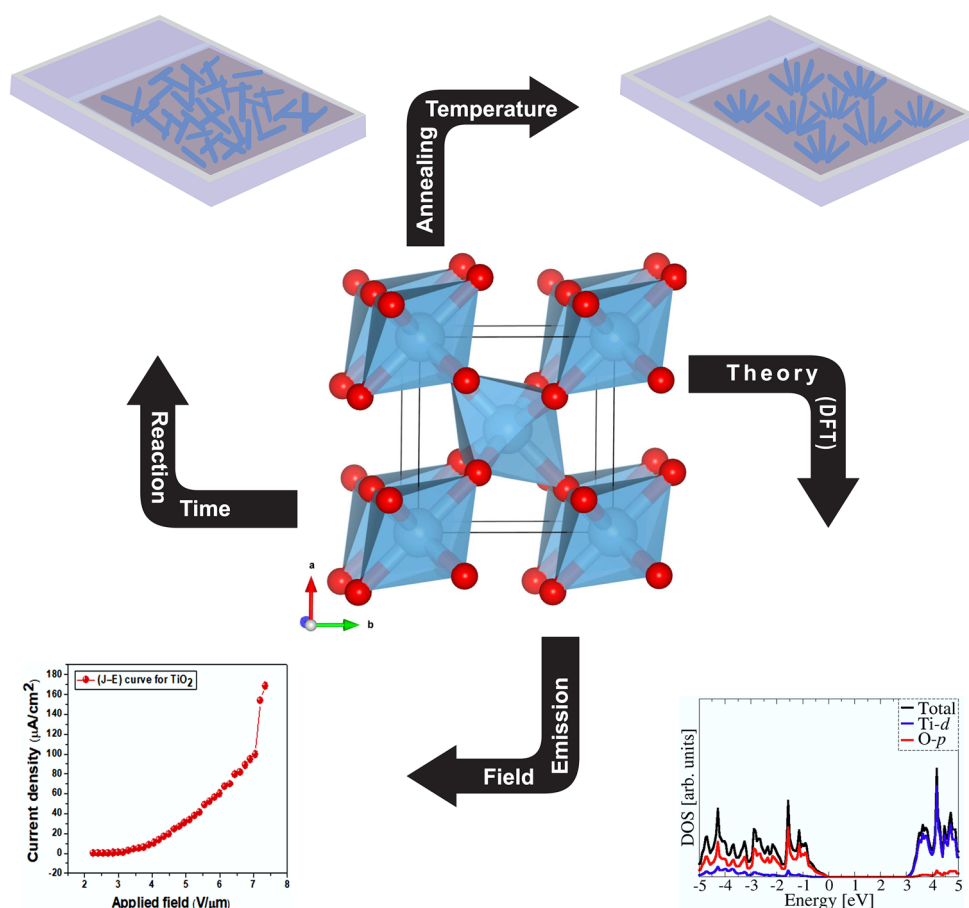
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Graphic Abstract



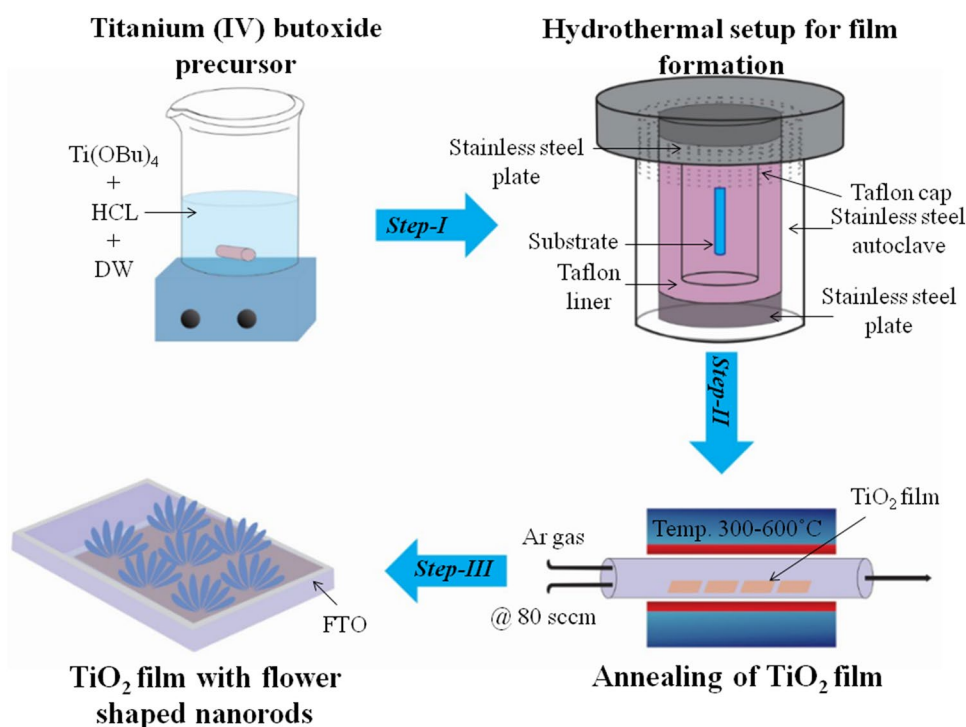
Keywords Titanium dioxide · Nanorods · Growth mechanism · Hydrothermal method · Density function theory · Field emission

1 Introduction

Nanocrystalline semiconductor materials have been attracting significant attention recently because of their unique physical and chemical properties that makes them attractive for application in industrial waste treatment (photocatalysis) and solar energy conversion (photovoltaics). Titanium dioxide (TiO₂) a wide bandgap material (3.4 eV) has emerged as the most studied of these photocatalysts owing to its high degradation efficiency with almost any organic molecule and many other attractive properties, including physical and chemical stability, low cost, good thin film transparency [1–5]. These germane properties make TiO₂ attractive materials for several applications including solar cell (DSSCs, QDSSCs, ETA Solar Cell) [6–10], photocatalysis [11], heterogeneous catalysis, environmental hazards removal [12], ceramics and paint

industries [13–15], gas sensors [16, 17], and supercapacitors [18–20]. Besides, owing to its non-toxicity and biocompatibility, TiO₂ is found appropriate for application in cosmetics, food products, pharmaceuticals, and in the biomedical applications [13]. These applications of TiO₂ are mainly dependent on their crystalline structure, particle size, optical properties, and morphology [4, 21–23]. Thus, one of the important aspects of the development of TiO₂ nanoscience is our ability to control its size and morphology for specific applications such as e.g. photoconversion in solar cell and field emission arrays [24, 25]. Crystallographically, TiO₂ is naturally present in three phases, i.e. anatase, rutile, and brookite, with the rutile phase been the thermodynamically most stable phase. The anatase and rutile phase exhibit tetragonal crystalline structure, whereas the brookite phase has an orthorhombic structure [26, 27]. A variety of methods have been developed for the synthesis

Fig. 1 Experimental setup of TiO_2 thin film formation using hydrothermal method



of TiO_2 nanoparticles with tailorable material properties like sol-gel [28–31], electrodeposition [32, 33], chemical vapor deposition [34], electrochemical anodic oxidation [35], spray pyrolysis [36], template-assisted [33], chemical bath deposition [37], hydrothermal methods [38, 39], and many others. Among these methods, the hydrothermal method is commonly used for synthesis of nanocrystalline TiO_2 as it offers the flexibility to attain different particle sizes and morphologies. Large-scale synthesis of TiO_2 nanoparticles with large surface area is also achievable with the hydrothermal method, hence its utilization in industrial-scale synthesis TiO_2 powders and thin films. Anderson et al. [40] reported the preparation of nanosize anatase and rutile TiO_2 by hydrothermal treatment of micro emulsions and investigated their activity for photocatalytic wet oxidation of phenol. Well-dispersed TiO_2 nano-crystals were synthesized by Yang et al. [41] using the hydrothermal methods. Rutile TiO_2 nanorods synthesized on a glass substrate at low temperature under hydrothermal condition was reported by Kakiuchi et al. [42]. Maurya et al. [43] investigated the effect of temperature on rutile TiO_2 using the hydrolysis method and observed that the crystallinity and density of rutile TiO_2 nanocrystals increases by increasing annealing temperature. The effect of repeated annealing temperature on the TiO_2 thin film and their structural, optical and electrical properties synthesized by dip coating sol-gel method was reported by Pakama et al. [44]. The hydrothermal synthesis of TiO_2 nanocrystals in

Table 1 Process parameters employed during the deposition of TiO_2 thin films

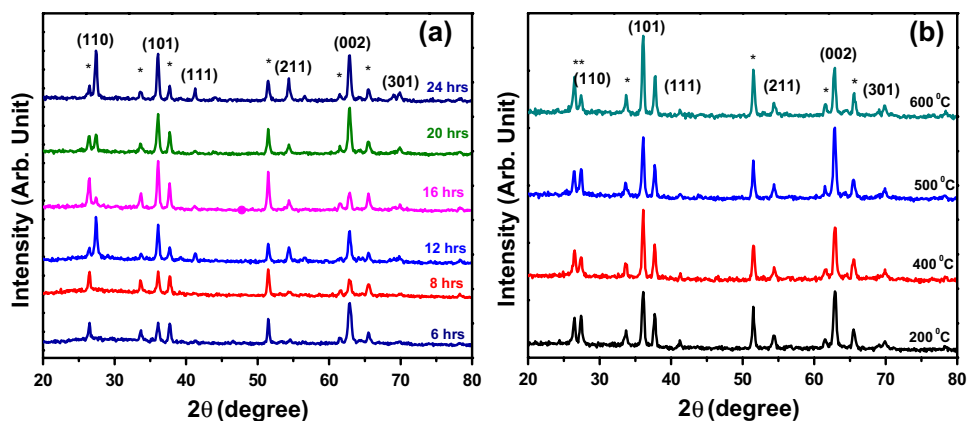
Deposition parameter	Set-I	Set-II
Concentration	50 mM Ti source	50 mM Ti source
Deposition time	6–24 h	20 h
Reaction temperature	150 °C	150 °C
Annealing temperature	500 °C	300–600 °C

The boldface text indicates the parameters varied in the set I and set II of experiments

different basic pHs and their applications in dye sensitized solar cells was reported by Anajafi et al. [45].

In the present work, synthesis of nano-structured TiO_2 thin films was carried out by hydrothermal technique, wherein the influence of different deposition parameters such as growth time, reaction temperature, and the film annealing temperature on the optical, structural and morphological properties have been investigated. The optical, morphological and structural characteristics of the synthesized TiO_2 thin films are studied by using various characterization methods such as X-ray diffraction (XRD), Raman spectroscopy, scanning electron microscopy (SEM) and UV-visible spectroscopy. The goal of the present work is to understand the correlation between the deposition parameters (reaction time and annealing temperature) and the growth mechanism of TiO_2 thin films. The

Fig. 2 X-ray diffraction patterns of TiO₂ thin films deposited at **a** different reaction times (6 h, 8 h, 12 h, 16 h, 20 h, 24 h) and **b** different annealing temperatures. The asterisk (*) indicate the peaks of the FTO



field-emission properties of the synthesized TiO₂ thin films are investigated and the results corroborated with first-principles density functional theory (DFT) calculations.

2 Experimental and computational details

2.1 Synthesis

All chemicals used in this work were analytical grade and used without further purification and treatment. For the synthesis of TiO₂ thin film, titanium (IV) butoxide (Sigma-Aldrich), hydrochloric acid (HCl), ethanol and distilled water were subjected to hydrothermal treatment. Commercially available FTO glass substrate was used for the growth of TiO₂ thin film. Titanium (IV) butoxide (5 g) was added to 10 ml HCl followed by the addition of 15 ml double distilled water. The resulting complex was then stirred at room temperature for half an hour using magnetic stirrer. The solution then transferred into locally fabricated cylindrical autoclave having dimensions 8 cm × 9 cm × 1 cm (height × diameter × thickness). The detailed structure of autoclave is schematically shown in Fig. 1. The FTO glass substrates were initially cleaned ultrasonically with double distilled water and followed by an acetone wash. Then substrates were put in ethanol solution for about 5 min. The substrates were again cleaned with double distilled water and finally given a nitrogen flush for drying. This cleaning procedure permits good adhesion of film to substrates. Then cleaned glass substrate was immersed in the solution in autoclave. After the addition of the reaction complexes and substrates, the autoclave was sealed tightly and placed in an oven at 150 °C for different reaction times ranging from 6 to 24 h for the set-I samples. The autoclave was allowed to cool naturally to room temperature. After cooling the film was taken out from autoclave and annealed at different temperature as shown in Table 1 for an hour. Two sets of films were deposited: in the first set, the TiO₂ thin films were

deposited at different reaction times i.e. from 6 to 24 h by keeping other parameters (concentration of the solution, deposition temperature, and annealing temperature) constant, whereas in set-II samples, the depositions was carried out with reaction time of 20 h for all the samples, with the annealing temperature varied from 300 to 600 °C and other deposition parameters were kept constant as listed in Table 1.

2.2 Material characterization

The average crystallite size, lattice parameter, inter planer distance, and phase identification of the deposited TiO₂ thin films were carried out using X-ray diffraction (XRD) pattern recorded using (Bruker D8 Advance machine, Germany) diffractometer with Cu Kα ($\lambda = 1.5418$ Å) radiation at a grazing angle of 1° and diffraction angle (2θ) ranging from 20° to 80°. Raman spectra were recorded with Raman spectroscopy (Jobin-Yvon Horibra LABRAM-HR) in the range of 200–1800 cm⁻¹. The spectrometer has backscattering geometry for detection of Raman spectrum with a resolution of 1 cm⁻¹. The excitation source was 632.8 nm line of He-Ne laser. The possibility of laser induced crystallization in the film was avoided by keeping the power of laser beam at < 5 mW. The optical bandgap of the TiO₂ films was estimated from transmittance and reflectance spectra of the films deposited on commercially available FTO glass substrates and were measured using a JASCO, V-670 UV-visible spectrophotometer in the range of 200–1100 nm. The morphological characteristics of the synthesized thin films are studied by a JEOL JSM-6360-LA and Philips XL-30 scanning electron microscope.

2.3 Computational details

The density functional theory (DFT) calculations were performed using the Vienna Ab initio Simulation Package (VASP) [46, 47], a periodic plane wave DFT code

Fig. 3 Raman spectra of TiO₂ films synthesized by hydro-thermal technique process **a** at different reaction times **b** at different annealing temperature

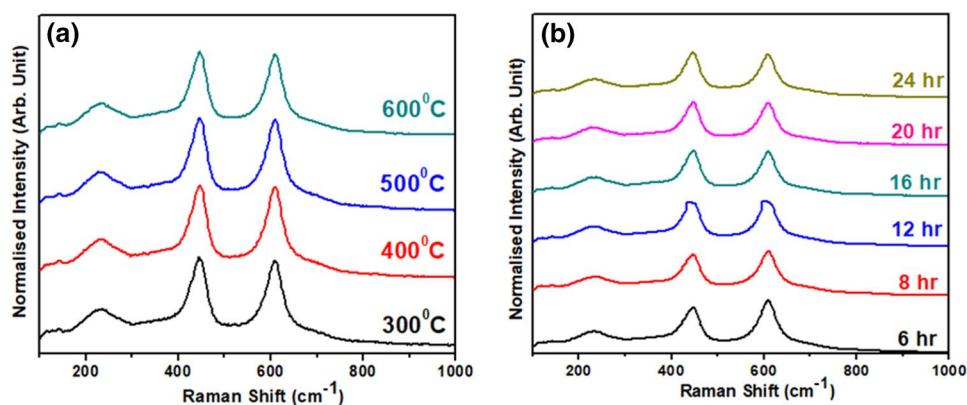
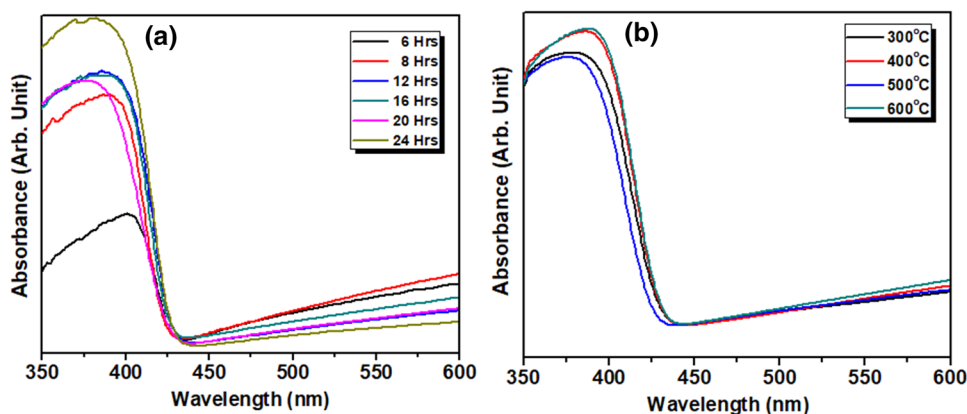


Fig. 4 Optical absorption spectra of TiO₂ thin films synthesized **a** at various reaction times **b** at different annealing temperatures



which includes the interactions between the core and valence electrons using the Project Augmented Wave (PAW) method [48]. The calculations were performed using the screened hybrid functional as proposed by Heyd–Scuseria–Ernzerhof (HSE06) [49]. A percentage of the exact non-local Fock exchange ($\alpha=0.25$) was added to the Perdew, Burke, and Ernzerhof (PBE) functional [50] with a screening of $\omega=0.11$ bohr⁻¹ applied in order to partition the Coulomb potential into long range (LR) and short range (SR) terms. An energy cut-off of 600 eV, and $9 \times 9 \times 3$ and $9 \times 9 \times 1$ Monkhorst–Pack k -point mesh [51], was used to sample the sample the Brillouin zone of TiO₂ bulk and (110) surface, respectively. All calculations were deemed to be converged when the forces on all atoms were less than 0.001 eV/Å. Rutile TiO₂ was modelled in the simple-tetragonal structure (Fig. 4a) with space group ($P4_2/mnm$) [52]. The optimized lattice constants were obtained at $a = b = 4.598$ Å, $c = 2.953$ Å, in close agreement with experimental lattice constants ($a = b = 4.594$ Å and $c = 2.959$ Å) [52]. The r-TiO₂(110) surface was created from the optimized bulk material using the METADISE code [53], which ensures the creation of surfaces with zero dipole moment perpendicular to the surface plane [54]. In order to align the energies to the vacuum level, a slab-gap model (slab thickness of 20 Å and vacuum size of 15 Å) was

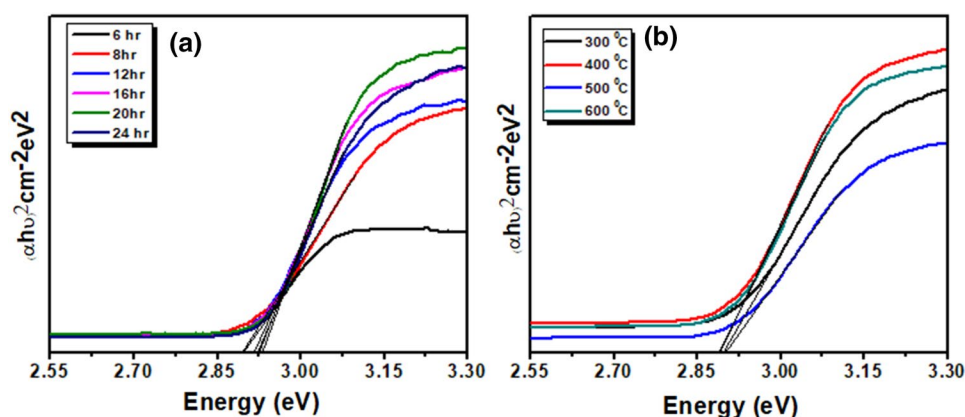
constructed and the corresponding electrostatic potential was averaged along the c -direction, using the Macro Density package [55–57], as displayed in Fig. 4(c). The work function (Φ), which is the minimum energy needed to remove an electron from the bulk of a material through a surface to a point outside the material was calculated as $\Phi = V_{\text{vacuum}} - E_F$.

3 Results and discussion

The XRD pattern of the set-I and set-II of TiO₂ thin films as described under the synthesis section are depicted in Fig. 2a, b, respectively. The peak position and relative intensity of the TiO₂ phases were confirmed by comparison with standard JCPDS database. The diffraction peaks located at $2\theta = 27.4^\circ, 36.1^\circ, 41.3^\circ, 54.4^\circ, 62.9^\circ$ and 69.9° corresponds to the (110), (101), (111), (211), (002) and (301) [58–61] planes of rutile TiO₂ phases (JCPDS no. 076-1939), respectively. No peaks of other phase were detected, thus confirming the successful synthesis of high-purity rutile TiO₂ using hydrothermal method.

The analysis of XRD patterns confirms tetragonal rutile phase of TiO₂ for both the sets. The comparatively broad shoulder located at $2\theta \sim 27.4^\circ$ is observed in all the films,

Fig. 5 The $(\alpha h\nu)^2$ versus $h\nu$ plots (Tauc's plots) of TiO_2 films synthesized **a** at reaction times between 6 and 24 h **b** at process temperature of 150 °C and duration of 20 h, (with annealing at 300 °C, 400 °C, 500 °C, 600 °C)



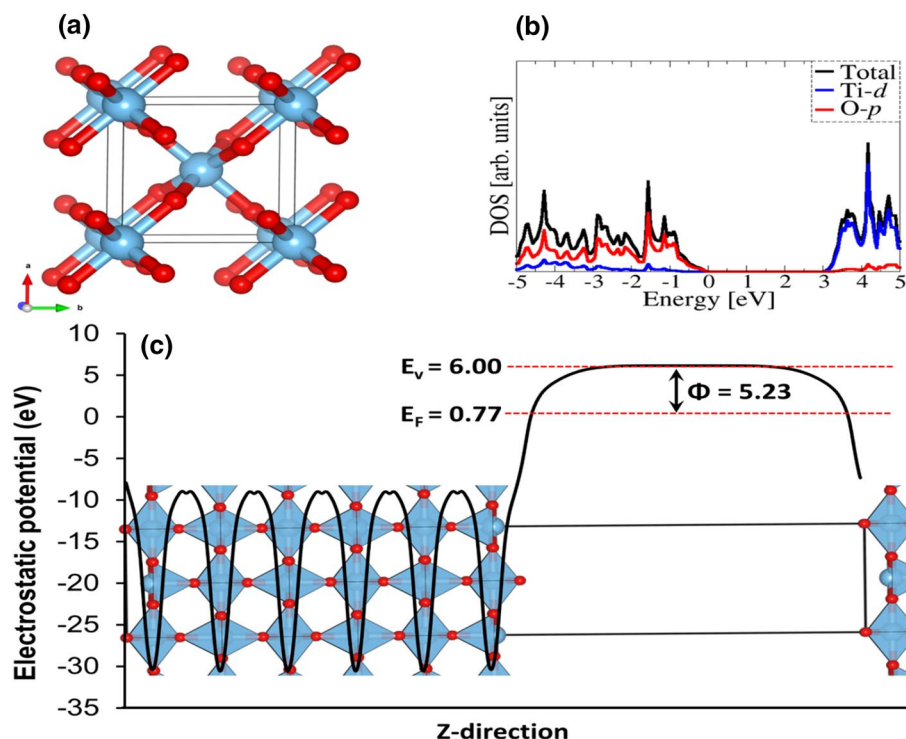
which is due to the x-ray diffraction occurring from parallel planar layers [62]. The inter planar distance for first order diffraction is 3.26 Å, which is very well matched with the reported values (3.06 Å) in literature [63]. The increased value of inter-planar distance in the present study is attributed to the presence of residual molecules intercalated between the material layers. The estimated lattice constants for the tetragonal structure is $a = b = 4.6038$ Å and $c = 2.957$ Å, which are in good agreement with the reported values in the literature [50]. The average crystallite size of TiO_2 is calculated by measuring FWHM in radian corresponding to (110) peaks by using the Scherer equation $d_{x\text{-ray}} = \frac{0.9\lambda}{\beta \cos(\theta)}$ where, λ is the wavelength of diffracted radiation, θ is the Bragg angle and β is the line width (FWHM) in radians. The crystallite size of TiO_2 was found to be in the range of 23 nm to 34 nm for the film deposited at different deposition time in set I; whereas the maximum crystallite size of 26 nm was observed at 600 °C annealing temperature in set II. In hydrothermal processes, the deposition time and annealing temperature promote the crystallization process. The observed variation in the crystallite size may be due to the non-uniform lattice strain.

The Raman spectroscopy is a resourceful technique used for a fast and non-destructive investigation of a wide-range of Raman active modes of material. Shown in Fig. 3(a, b) are the Raman spectra for both sets of synthesized TiO_2 thin films. Four prominent peaks located at 143.2 cm^{-1} , 235.6 cm^{-1} , 447.1 cm^{-1} and 607.9 cm^{-1} are evident and can be assigned to Raman active mode with the symmetry of E_g for rutile TiO_2 characterized by the tetragonal space group of $I4_1/amd$ and A_{1g} , B_{1g} , and E_g which is illustrated by the tetragonal space group of $P4_2/mnm$ for rutile TiO_2 [64–69]. The two prominent maxima peaks located at 447.1 cm^{-1} (E_g) and 607.9 cm^{-1} (A_{1g}) correspond to O–Ti–O bending vibrations and Ti–O stretching vibrations of monoclinic rutile TiO_2 phase, respectively [37, 67]. The observed prominent Raman shift at 235.6 cm^{-1} , 443 cm^{-1} , 610 cm^{-1} , corresponds to B_{1g} , E_g , A_{1g} active

mode of bulk rutile TiO_2 , as reported by Begun et al. [70]. Raman shift peak positions shown in the Fig. 3 are in good agreement with those reported in the literature, indicating that synthesized TiO_2 is in the rutile phase. The Raman shift peak at 235 cm^{-1} is attributed to compound vibration peak arising due to multiple phonons scattering process, which is also considered a Raman peak of rutile [71]. There is no observation of Raman active mode for brookite and other organic species impurity phases, which lead us to conclude that the hydrothermal method is the suitable for the synthesis of high-quality rutile TiO_2 thin films for device fabrication.

The optical properties of TiO_2 thin films grown by hydrothermal on FTO glass were investigated from UV–visible spectroscopy. Figure 4 shows the optical absorption spectra of the TiO_2 thin films synthesized using hydrothermal technique at different reaction times and at different annealing temperatures. All the samples synthesized at different reaction times and at different annealing temperatures show sharp absorption edge at 423–430 nm. It also evident from Fig. 4 that the absorption edge shifts towards lower wavelength with increasing reaction times. The shift in the absorption edge towards lower wavelength is attributed to change in the TiO_2 particle size. All the synthesized TiO_2 thin films exhibit very strong and broad UV–visible absorption, similar to the observation by Xie et al. [38, 72] This characteristic is in agreement with the photo-protection function of the TiO_2 films thus formed, making them potential candidates for solar photon capture for photo electrochemical applications. The samples however, show a low absorption above 423 nm, which can be attributed to oxygen vacancy defect formation at the surface boundaries of TiO_2 [73] induced by the higher annealing temperatures. It leads to change of shape of the fundamental absorption edge of the material. As can be seen from Fig. 4, the absorption increases exponentially towards shorter wavelengths, similar to previously reported absorption spectra in the literature [74–76].

Fig. 6 **a** Crystal structure of the rutile TiO_2 ; **b** the partial density of states (PDOS) and **c** the electrostatic potential of the (110) surface along coordinate Z considering vacuum as reference energy. E_F , E_v and Φ correspond to the Fermi, vacuum energy and work function of the defined surface. The light blue and red balls correspond to Ti and O atoms, respectively



The optical band gap of the thin films was calculated from the dependence of the absorption coefficient (α) on the photon energy ($h\nu$) using Tauc relation: $(\alpha h\nu) = B(h\nu - E_{\text{Tauc}})^2$, where B is Tauc's constant which is a characteristic parameter independent of photon energy, α is the absorption coefficient, h is the Planck's constant, ν is photon frequency, and E_{Tauc} is the bandgap of the material. The E_{Tauc} estimate can be deduced by plotting $(\alpha E)^2$ versus E and extrapolating the linear portion of the plot to the energy axis. Figure 5 shows the $(\alpha h\nu)^2$ versus $(h\nu)$ photon energy plots for the TiO_2 thin films prepared at different reaction times and annealing temperatures. The intercept of the plotted tangent gives a good approximation of the band gap energy for this material. The band gap decreases from 2.9 to 2.8 eV when deposition time increases from 6 to 24 h. It is interesting to note that these values are smaller than the reported values of synthetic TiO_2 thin films [77–79]. From the absorption graph, it is confirmed that TiO_2 thin film responds the UV–visible region. The optical absorption of the synthesized sample was found between 423 and 430 nm which corresponds to the band gap of TiO_2 (2.9 eV).

We have employed first-principles DFT calculations to gain insight into the electronic structure and work function of rutile TiO_2 as the field emission properties are strongly dependent on the work function (Φ) of the emitter. Shown in Fig. 6 is the crystal structure of r-TiO_2 with the corresponding electronic partial density of state (PDOS). The badgap is predicted at 3.01 eV, which is good

agreement with our experimental measurements and previous DFT calculations [80–82]. An analysis of PDOS reveals that valence band edge is composed mainly of the O- p whereas the and conduction band edge is composed mainly of Ti- d states, indicating that r-TiO_2 is a O- p –Ti- d charge transfer semiconductor, which agrees with earlier theoretical predictions [80–82]. The work function was obtained for the most stable (110) surface of r-TiO_2 , which was cleaved from the geometrically optimized bulk. A vacuum region of length 15 Å was used in the perpendicular direction to the r-TiO_2 (110) plane to avoid spurious interactions with its own periodic image. Figure 6c shows the structure of the r-TiO_2 (110) surface and the corresponding electrostatic potential as a function of coordinate Z (along the c-axis). The work function (Φ) is calculated as the difference between the potential energy of one electron between the Fermi level (E_F) and the vacuum level (E_v). The vacuum level is the potential energy, approaching a nearly constant value in the energy distributions in the vacuum region, which is obtained at 6.00 eV in the present study. The work function of the r-TiO_2 (110) surface is predicted at 5.23 eV, in excellent agreement with the values of 5.2–5.5 eV estimated from ultraviolet photoelectron spectroscopy measurements [83–87].

Scanning electron microscopy (SEM) is a convenient method for studying morphology and growth mechanism of the TiO_2 nanorod on the FTO substrates. In the first part, we have investigated the effect of deposition time on growth mechanism of TiO_2 nanorods whiles

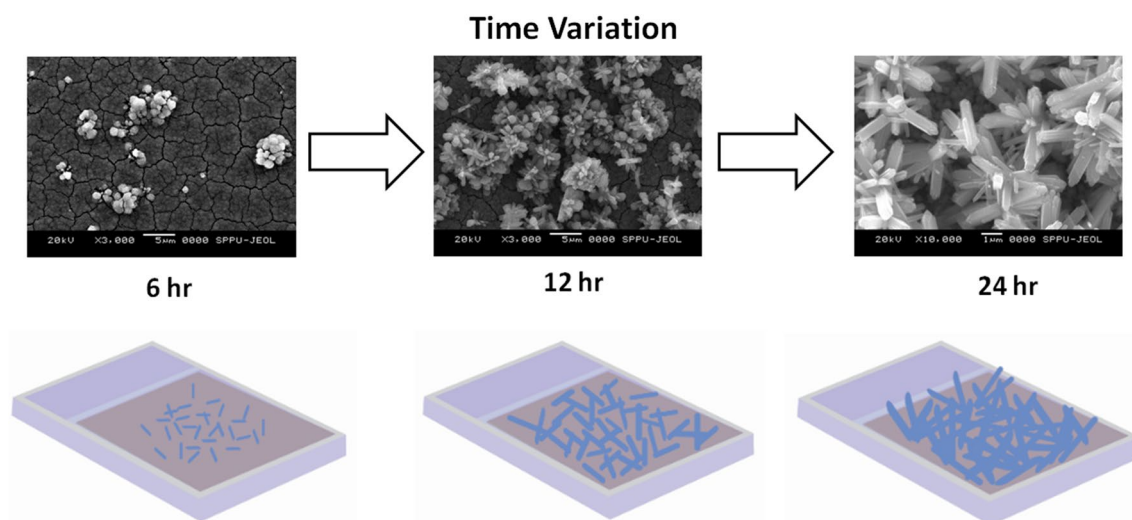


Fig. 7 Scanning electron microscopy (SEM) micrographs of TiO_2 thin films at different reaction times (6, 12, and 24 h)

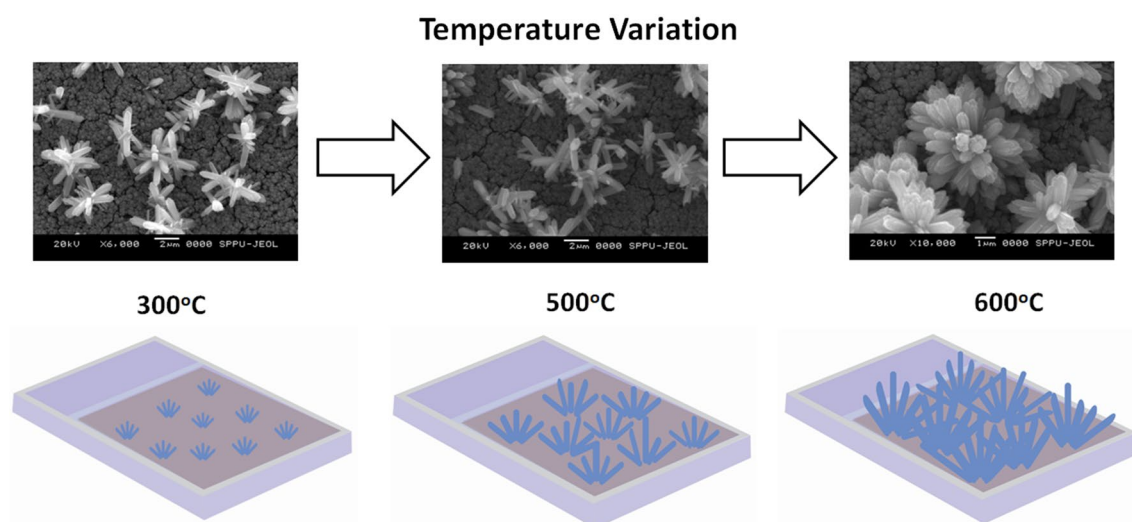


Fig. 8 Scanning electron microscopy (SEM) micrographs of TiO_2 thin films at different annealing temperatures (300 °C, 500 °C, and 600 °C)

keeping other deposition parameters constant. Shown in Fig. 7 are the SEM images of TiO_2 films at different reaction time. It is clear from the SEM images that an increase in the reaction time leads to enhancement in the growth of TiO_2 nanorods. The TiO_2 nanorods started to grow on FTO substrate at the initial reaction time (6 h), which increased in density after 12 h and at 24 h reaction time, the growth of the TiO_2 nanorods covers almost the entire surface areas of the FTO substrate. Shown below each SEM image is the schematic of the nature of the growth process, revealing the growth initiation at 6 h, increased density and random growth after 12 h, and nearly full coverage of TiO_2 nanorods on the FTO substrate at 24 h. Although there is clear evidence of enhanced growth of TiO_2 nanorods

with increasing reaction times, we could not control preferential growth orientations of TiO_2 nanorods on FTO substrate in hydrothermal synthesis. In the second part, we have focused on the annealing temperature after synthesis of TiO_2 nanorods in the hydrothermal method. The Fig. 8 shows images of TiO_2 nanorods at different annealing temperatures. We observed clear difference in the growth process of the TiO_2 nanorods at annealing temperature as 300 °C, 500 °C, and 600 °C. At 300 °C, the TiO_2 nanorod started growing in FTO substrate in spherical microstructures. The initial stage of the growth process was limited by the premature termination of the growth surface, but with increased annealing temperature, the regularly shaped particles were transformed to onset of nano-rod

Fig. 9 Atomic force microscopy (AFM) images of TiO₂ thin films at 24 h reaction time, **a** 2-dimensional (2D) AFM image and **b** 3-dimensional (3D) AFM image

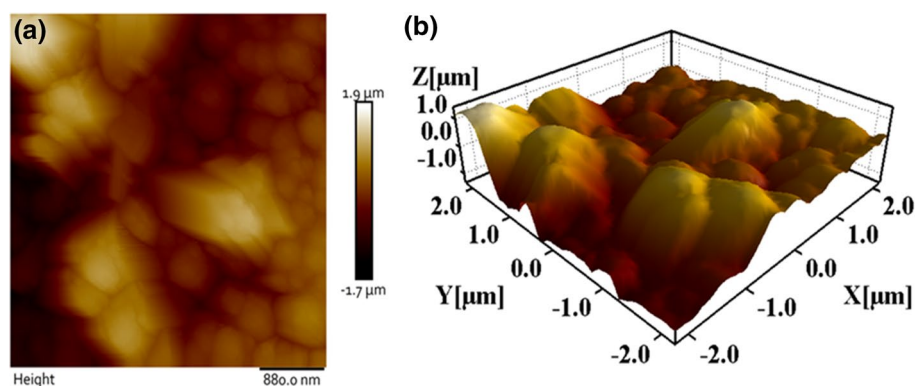
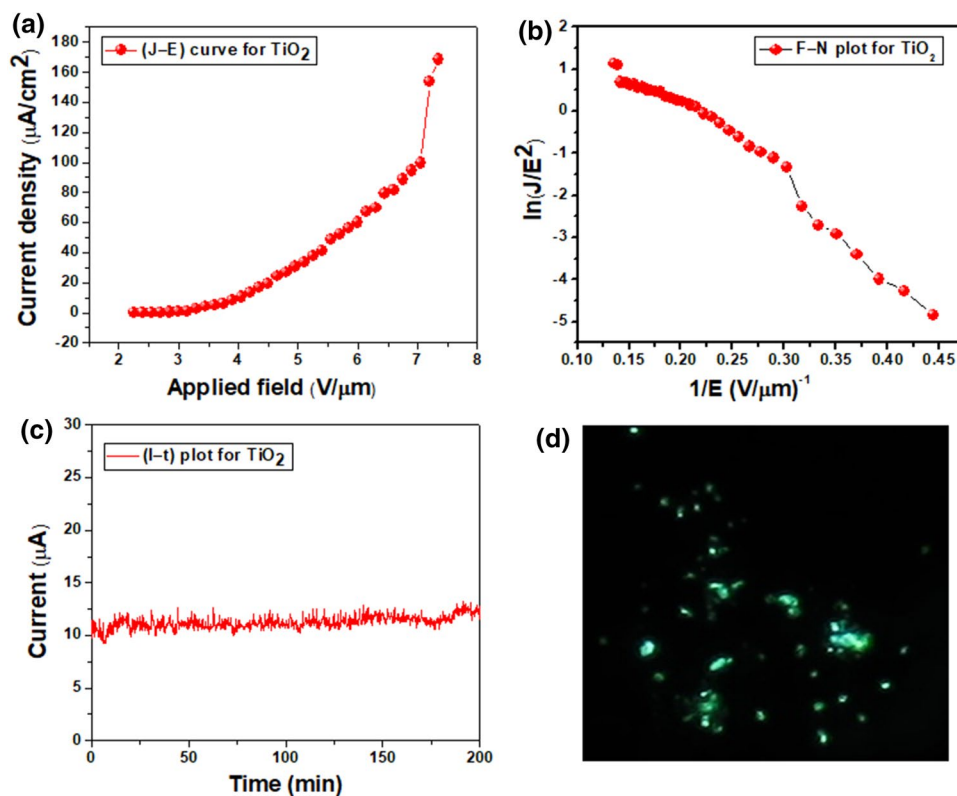


Fig. 10 The field emission properties from TiO₂ nanorods **a** current density (*J*) versus applied field (*E*), **b** Fowler–Nordheim (F–N) plot showing non-linear behavior, **c** current stability at 10 μA and **d** photograph of field emission pattern



bunch morphology and further to bunch of nanorods with anchoring on the ITO substrate. Compared to the random growth nature observed with different reaction times as in set I, the growth of the TiO₂ nanorod is pronounced in its random nature with changing annealing temperatures as in set II. The growth of the TiO₂ nanorod on the FTO substrate resembles the growth of a flower in all directions. In schematic diagrams below the SEM images in Fig. 8, we demonstrate how the TiO₂ nanorods grow in uniform shape in a control manner. After the annealing temperature was increased to 500 °C, the TiO₂ nanorod density increased thereby showing the growth of nanorods from a point on the substrate and at 600 °C, the TiO₂ nanorods clearly look like a bunch of flowers. This demonstrates that

by varying the annealing temperature we can grow TiO₂ nanorod in a control manner with flower like morphology. The TiO₂ thin films prepared by the hydrothermal technique are without pinholes and provided continuous coverage on the substrate. The uniformly formed rod-like structures of TiO₂ material makes the synthesized thin films better candidates for solar cell (DSSCs) and field emitter arrays applications.

The TiO₂ thin films were characterized using AFM technique and shown in Fig. 9 are the 2-dimensional (2D) and 3-dimensional (3D) AFM images of the TiO₂ thin film at 24 h reaction time. The average roughness and root mean square (RMS) roughness for TiO₂ thin film estimated at 418 nm and 518 nm, respectively.

The pointed nanorod-like TiO_2 structures are fascinating structures and may be suitable for several applications including as field emitter arrays. We have thus investigated the field emission properties of the TiO_2 nanorods as shown in Fig. 10: (a) current density (J) versus applied field (E), (b) F–N plot, (c) current stability at 10 μA , and (d) photograph of field emission pattern. The current density (J) is defined $J = I/A$, where I is the emission current and A is the area of emitter. The applied field (E) is defined as $E = V/d$, where V is the applied voltage, and d is the separation between the anode and cathode. According to Fowler–Nordheim (F–N) theory, in J – E plot, the emission current from surface of emitter varies as exponentially [88]. TiO_2 nanorods J – E plot showing exponential function. The electron emission quantum tunneling turn on and threshold field were found to be 4.06 and 7.06 $\text{V}/\mu\text{m}$ at emission current densities of 10 and 100 $\mu\text{A}/\text{cm}^2$ respectively of TiO_2 nanorods. These values suggest that better turn on field of TiO_2 nanorods are recorded as compared to the ones reported in literature [89–91]. We have obtained the maximum current density of the TiO_2 nanorods to be 168 $\mu\text{A}/\text{cm}^2$ at an applied field of 7.35 $\text{V}/\mu\text{m}$. The F–N plot of TiO_2 nanorods defined by $\ln(J/E^2)$ versus $1/E$ (Fig. 10(b)) shows a non-linear behavior, which is consistent with the semiconductors nature of the TiO_2 emitter. The emission current stability is very important for practical applications as cold cathode. The emission current (I) versus time (t) plot of the TiO_2 nanorods at 10 μA remained fairly stable for more than 3 h as shown Fig. 10c. The observed fluctuations and spikes in emission current may be due to the adsorption or desorption of residual gas atoms/molecules on the surface of TiO_2 nanorod emitter in the presence of applied field. The field emission of TiO_2 nanorods patterns is shown Fig. 10d with the tiny bright spots representing electron emission from protruding sites of TiO_2 nanorods on the fluorescent screen as electron collector.

4 Conclusion

Large-area, very dense, and pin-hole free TiO_2 nanorod thin films were successfully synthesized by a simple and cost effective hydrothermal method. The effect of reaction times and annealing temperatures on the growth mechanisms (size and shape) of the TiO_2 nanorods was systematically studied. The TiO_2 nanorods are demonstrated to grow randomly on the FTO substrate with changing reaction times but grow uniformly in a flower-like pattern with increasing annealing temperature. Recorded X-ray diffraction patterns, UV–VIS spectra, and Atomic force microscope images showed that the crystallinity in TiO_2 thin films is significantly affected by increasing annealing temperature. The optical properties investigated

experimentally and further corroborated with first-principles density functional theory calculations show the TiO_2 thin films have high absorption coefficient and a direct bandgap in the range 2.8–3.0 eV, which is slightly smaller than the bandgap of bulk rutile TiO_2 . The TiO_2 nanorods exhibit moderate field emission properties and have turn on field of 7.35 $\text{V}/\mu\text{m}$ and good field emission stability. These results indicate that TiO_2 nanorods thin films may be promising candidates for applications in electron-emitting nano devices.

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Compliance with ethical standards

Conflict of interest On behalf of all authors, the corresponding author states that there is no conflict of interest.

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